ENGI 5131 Midterm Sample Problems — Winter 2013

ACM parameters: $I_{SQn} = 280$ nA, $V_{thn} = 0.5$ V, $|\partial L/\partial V_{DS}|_n = 0.03 \ \mu m/V$, $I_{SQp} = 80$ nA, $V_{thp} = -0.55$ V, $|\partial L/\partial V_{DS}|_p = 0.04 \ \mu m/V$, $L_D = 0$ and $n_n = n_p = 1.31$.

Problems and Questions

- 1. Design a simple PMOS current mirror subject to the following specifications:
 - Supply voltage is 3 V.
 - The operating output voltage range must be from zero up to 2.75 V.
 - The input and output currents are equal to 60 μ A.
 - The output current must change by 3 % or less with a decrease of 1 V in the output voltage (V_{out}) .
 - Minimize gate area as much as possible.

Show the schematic with transistor dimensions for full marks.

- 2. Re-design the previous current source for an input current of 200 μ A and an output current of 50 μ A. Use unit transistors for good matching.
- 3. Calculate the resistor needed to generate the input current in Problem 2.
- 4. Neglecting channel-length modulation, estimate the difference between the input and output currents in your design in Problem 1 when V_{th} mismatch between transistors is 15 mV.
- 5. Design a CS amplifier with current-mirror load as shown in the figure for a gain of at least 180 and an output voltage swing of at least ± 1 V. The supply voltage is $V_{DD} = 3$ V, the reference current is 100 μ A and $L \geq 1 \mu$ m for all transistors. Try to minimize area.



- 6. Calculate the DC input voltage required in the amplifier that you designed in the previous problem.
- 7. In the amplifier shown below, what is the maximum small-signal gain that can be achieved? Justify your answer. You are free to adjust all other circuit parameters.



8. Given $(W/L)_2 = 0.5$, $V_{DS1} = 0.2$ V and $V_{DD} = 3$ V, calculate what is the maximum gain that can be achieved by the circuit shown below:



- 9. For an inverter with minimum gate length (0.4 μ m) and $W_p = 5 \ \mu$ m, estimate W_n for a threshold voltage equal to 1.5 V with a supply voltage of 3 V (you can use strong inversion equations).
- 10. The following layout is for a transistor in a process with p-type substrate.
 - What layer is missing to form an NMOS transistor?
 - What layers are missing to form a PMOS transistor instead?



- □ Active (thin oxide)
- 🖾 Poly
- Metal 1
- Contact